## **AMENDMENTS TO THE CLAIMS**

Please cancel claims 12 and 14 and amend claims 11, 13, and 15-17, such that the status of the claims is as follows:

1. (Withdrawn)

3. (Withdrawn)

2. (Withdrawn)

- 4. (Withdrawn)
- 5. (Withdrawn)
- 6. (Withdrawn)
- 7. (Withdrawn)
- 8. (Withdrawn)
- 9. (Withdrawn)
- 10. (Withdrawn)
- 11. (Currently Amended) A method for oblique deposition onto a substrate, the method comprising:

directing vaporized species from a vapor source positioned at an oblique angle to the substrate toward [[a]] the substrate at a distribution of angles of incidence about an angle  $\theta$  measured relative to a surface normal of the substrate;

rotating the substrate about an axis of rotation while depositing the vaporized species on the substrate; and

narrowing the angular distribution distribution of angles of incidence by permitting only a portion of the vaporized species traveling at approximately the angle  $\theta$  to pass through an aperture in a shadow mask positioned between the vapor source and the substrate, wherein the aperture extends in a radial direction with respect to the axis of rotation of the substrate.

## 12. (Canceled)

13. (Currently Amended) The method of claim 11 wherein the distribution of [[the]] angles of incidence is narrowed by intercepting a portion of the vaporized species not traveling at about the angle  $\theta$ , wherein the species are intercepted with [[a]] the shadow mask.

## 14. (Canceled)

15. (Currently Amended) The method of claim [[14]] 11 comprising the additional step of forming a single continuous film of the vaporized species wherein the <u>distribution of</u> angles of incidence of the vaporized species are organized into azimuthal symmetry.

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16. (Currently Amended) The method of claim [[14]] 11 comprising the additional step of forming a single continuous film of the vaporized species wherein the <u>distribution of</u> angles of incidence of the vaporized species are organized into a circumferential pattern.

17. (Currently Amended) The method of claim [[14]] 11 comprising the additional step of forming a single continuous film of the vaporized species wherein the <u>distribution of</u> angles of incidence of the vaporized species are organized into a radial pattern.

- 18. (Withdrawn)
- 19. (Withdrawn)
- 20. (Withdrawn)